

# Functional Printing at JOANNEUM RESEARCH





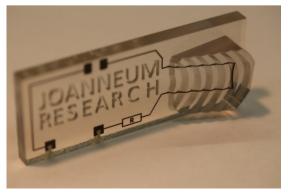
### Functional Printing at JR

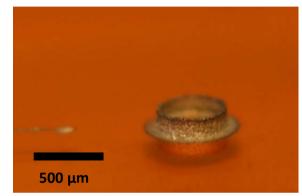
#### **Development fields**

- Novel Ink
   Formulations
- ProcessDevelopment
- Mix+Match Approaches
- Integration of Novel Technologies
- Prototyping

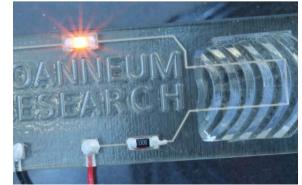












#### **Applications**

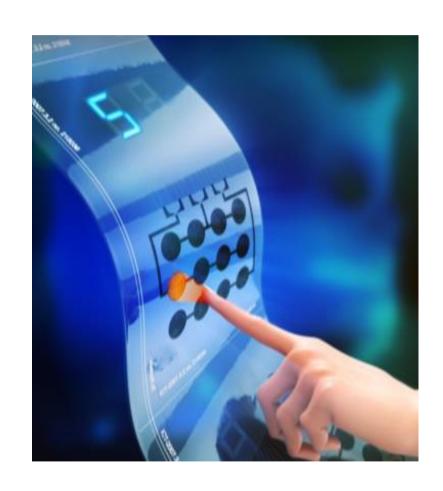
Hybrid Electronics
Printed Circuitry with
SMD components on
flexible substrates

Printed Sensors
Passive T+p
Active T + RH

<u>Functional 3D</u><u>Structures</u>3D Integrated CurcuitryIntegrated Sensors

## We cover the entire process chain

- Definition and Specification
- Ink development
- Substrate Pretreatment
- Print strategy (Aerosoljet, Inkjet, Screen, ...)
- Post-Processing
- Characterisation
- Prototype Fabrication & Small Batch Production





- Ink (e.g. photoresists, metal inks, insulators, adhesives, etc.)
  - Adaptation of available inks
  - Development and Formulation of Novel Inks
  - Ink Characterisation (Viscosity, Surface Tension,....)
  - Printability Tests
- Substrate (e.g. silicon wafer, polymers, glas, ceramics, etc.)
  - Substrate Characterisation (LM, AFM, SEM, Surface Energy,...)
  - Substrate Functionalisation (plasma, ozone, HMDS treatment,...)
  - UV-Nano-Imprint Lithography (also in a roll-2-roll version for flexible substrates)

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- Development of Single or Mix&Match Approach Printing Processes (e.g. for photoresist coatings, circuitry, antenna structures, electrodes, sensors, etc.)
  - Inkjet
  - Aerosoljet
  - Screen printing
  - Solenoid Valve
  - ESJET (Electrostatic Jet Printing)
  - Flexography
  - Customised Hardware Integration/Adaptation for PIXDRO LP50 system (e.g. Solenoid Valve, ESJET, MicroFab Single Nozzle, etc....)

- Printing Process Development targeted to the customer's applications:
  - Printability Studies
  - Printhead Evaluation
  - Ink Evalution
  - Waveform Optimisation
  - Dropwatcher Experiments
  - Printing Strategy Development and Optimisation



### Post Processing

- Thermal Treatment (Oven, Vacuum oven, hot plate)
- Photonic Curing (UV, IR laser)
- Optimisation of Curing Parameters
- Evaluation of Substrate Compatibility

#### Characterisation

- Fluorescence microscopy
- AFM
- SEM
- Conductivity Tests
- Stability Tests
- Etc.

THE INNOVATION COMPANY

### Contact

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